

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Kuei

Kuei-Jen Chang

Group Art Unit: 1763

Serial No.: 09/822,749

Examiner: Mulero Luz L. Alejandro

Filed:

March 30, 2001

In Response to Office Action

Dated:

October 11, 2002

For:

Method and Apparatus for In-Situ Descum/Hot Bake/Dry

Etch Photoresist/Polyimide Layer

Attorney Docket No.: 67,200-397

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Certificate of Mailing

I hereby certify that this paper (along with any referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to Assistant Commissioner for Patents, Washington, D.C. 20231

Date: January 10 2002

JAN 23 2003
TECHNOLOGY CENTER 1700

RESPONSE TO OFFICE ACTION

Assistant Commissioner for Patents Washington, D.C. 20231

Dear Sir:

In response to an Office Action mailed October 11, 2002, please consider the following remarks.